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VUV/UV light inducing accelerated phenol degradation with a low electric input†

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This study presents the first evidence for the accelerated degradation of phenol by Fenton's reagent in a mini-fluidic VUV/UV photoreaction system (MVPS). A low-pressure mercury lamp used in the MVPS led to a complete degradation of phenol within 4–6 min. The HO[•] and HO₂[•] originating from both Fenton's reagent and VUV photolysis of water were identified with suitable radical scavengers. The effects of initial concentrations of phenol, H₂O₂ and Fe³⁺ as well as solution pH on phenol degradation kinetics were examined. Increasing the initial phenol concentration slowed down the phenol degradation, whereas increasing the initial H₂O₂ or Fe³⁺ concentration accelerated the phenol degradation. The optimal solution pH was 3.7. At both 254 and 185 nm, increasing phenol concentration enhanced its absorption for the incident photons. The reaction mechanism for the degradation of phenol was suggested consistent with the results obtained. This study indicates that the VUV/UV photo-Fenton process has potential applications in the treatment of industrial wastewater containing phenol and related aromatic pollutants.

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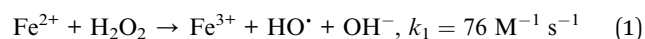
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Introduction

Industrial wastewater decontamination has been a research topic during the last few decades directed to abate toxic and recalcitrant pollutants of industrial origin.^{1–3} Phenol can only be degraded slowly by bacteria with low to moderate concentrations in mixtures of biodegradable and non-biodegradable pollutants in industrial wastewaters.^{4–8} Phenols, bi-phenols, chloro-phenols and nitro-phenols need at the present time a lower cost removal system working within an acceptable time than the biological and chemical methods currently available.^{9,10} Some advanced oxidation processes (AOPs) have used preferentially TiO₂ as a photocatalyst for this purpose. TiO₂ generates highly oxidative radicals under band-gap irradiation (band gap of 3.0–3.2 eV).^{11–14} Under UV or UV-Vis irradiation, TiO₂ and doped-TiO₂, either suspended in aqueous solutions or fixed on suitable substrates, have been applied to degrade phenol with relatively slow kinetics.^{15–20} Moreover, to increase the dispersion and light absorption of TiO₂ and doped-TiO₂, Raschig-rings have been used as supports to accelerate the phenol degradation kinetics.^{21,22}

The degradation of phenol(s) by AOPs at current remains slow and inefficient in spite of recent improvements in reactor technology, lamp design and other engineering aspects. Fenton and photo-Fenton studies in homogeneous/heterogeneous systems leading to phenol degradation have increased in recent years. Esplugas *et al.* reported a time of *ca.* 10 min for phenol degradation.²³ More recently, Zazo *et al.* reported a time of *ca.* 4 h for a complete degradation of phenol by Fenton's reagent.²⁴ The authors also reported the phenol degradation intermediates: catechol, hydroquinone, *p*-benzoquinone and resorcinol, followed by short organic-acids branched or not before the final mineralization.²⁴ Pontes *et al.* reported phenol degradation within 40 min in homogeneous solution,²⁵ and by Friedrich *et al.* within 45 min.²⁶ Heterogeneous Fenton and photo-Fenton using Fe-clinoptilolite led to a phenol reduction within 35 min,²⁷ while clay pillared-Fe led to a phenol reduction within 120 min.²⁸ Pillared montmorillonite Fe and clay/silica/zeolite reduced phenol within 60 and 120 min, respectively.^{29,30}

The mechanism for the homogeneous catalysis of H₂O₂ leading to highly oxidative radicals in the dark has been reviewed.^{31–33} The fully hydrated Fe(H₂O)₆³⁺ complex was reported as a catalytic species in the Fenton system at pH < 3.³⁴ At pH ≤ 3.5, the complexes Fe(OH)(H₂O)₅²⁺ and Fe(OH)₂(H₂O)₄⁺ interact with H₂O₂ in the Fenton system, which has been comprehensively described.^{35,36} These Fe-aqua complexes have optical absorption up to 390 nm.^{7,8} The basic Fenton reactions are presented in eqn (1)–(4), whilst eqn (5) and (6) refer to the photo-Fenton reactions. Note that in eqn (4) and (5), Fe(OH)²⁺ represents a simplified form of Fe(OH)(H₂O)₅²⁺.

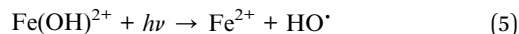
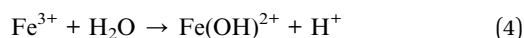


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The photo-Fenton reactions presented in eqn (5) and (6) generate additional HO^\bullet through the light activated reduction of Fe(OH)^{2+} and the direct photolysis of H_2O_2 . This accelerates the degradation of organic compounds compared to the dark Fenton system.³⁴ The HO^\bullet generated led in the first reaction step to an aromatic ring addition to the phenol, leading to the hydroxyl-cyclohexadienyl radical.^{37,38}

The objective of this study was to achieve an accelerated degradation of phenol by the Fenton's reagent ($\text{Fe}^{2+/3+}/\text{H}_2\text{O}_2$) in a more advanced photo-reactor by way of VUV/UV irradiation. Due to a short degradation time and a low electric input, this VUV/UV photo-Fenton process only required a low energy consumption. The experiments were carried out in a mini-fluidic VUV/UV photoreaction system (MVPS), which provided VUV/UV or UV irradiation with an accurate quantification of UV fluence. The light absorption by each of the solution components in the photo-reactor was determined as well as the identity of intermediate oxidative radicals. The effects of initial phenol concentration, initial H_2O_2 concentration, and solution pH on phenol degradation kinetics were examined in detail. The reaction mechanism leading to phenol degradation was also suggested.

Experimental section

Chemical reagents and analytical methods

All solutions were prepared in ultrapure water produced from a Milli-Q system (Advantage A10, Millipore, USA). Chemicals used were of at least reagent grade and purchased from Sigma-Aldrich (St. Louis, MO, USA) or Thermo Fisher Scientific (Fair Lawn, NJ, USA). Fenton experiments were conducted employing FeCl_3 and H_2O_2 (~35% by weight). The initial pH was adjusted by NaOH and HCl solutions. 1,4-Benzoquinone (BQ) and *tert*-butanol (TBA) were used as $\text{O}_2^{\cdot-}$ and HO^\bullet scavengers, respectively. Uridine (0.12 mM) and methanol (0.10 mM) were utilized as chemical actinometers to determine the UV fluence rate output from the MVPS.

Phenol concentration was determined by using a high-performance liquid chromatograph coupled with a photodiode-array detector (HPLC/DAD, Agilent Technologies, US). Methanol concentration was determined by a gas chromatograph equipped with a flame ionization detector (GC/FID, Shimadzu, Japan). Uridine concentration was measured by light absorption at 664 nm on a UV-Vis spectrophotometer (2600, Shimadzu, Japan) directly linked to the MVPS. H_2O_2 concentration was measured by Titanium(IV) oxysulfate (TiOSO_4) with a detection limit of 0.01 mg L^{-1} .³⁹ Total organic carbon (TOC)

was analyzed with a TOC analyzer (TOC-VCPh, Shimadzu, Japan).

VUV/UV and UV irradiations in the MVPS

To overcome the limitations of traditional batch VUV/UV photo-reactors, an innovative design of a bench-scale MVPS was developed in our previous study (see Fig. S1†).^{39,40} The photo-reactor chamber was cylindrical (length = 300 mm, outer diameter = 40 mm) with a jacketed quartz-wall. An 8 W low-pressure mercury lamp (arc length = 200 mm, Wanhua Co., Zhejiang, China) manufactured by synthetic quartz was housed in the center of the photo-reactor, which could emit both 185 (VUV) and 254 nm (UV) beams. Cooling water was recirculated through the outer chamber at a constant temperature to maintain stable VUV and UV outputs from the LP lamp. A synthetic quartz tube (*i.e.*, VUV/UV tube, high VUV transmittance) and a Ti-doped silica tube (*i.e.*, UV tube, no VUV transmittance) were installed parallel to the lamp in the photo-reactor chamber with the same distance (*ca.* 5 mm) to the lamp surface. The inner diameter and length of both tubes were 2 and 100 mm, respectively. The reaction solution flowing through the VUV/UV and UV tubes could receive the 185/254 nm and the 254 nm irradiations, respectively. Nearly same UV (at 254 nm) fluence rate (FR) could be obtained in the VUV/UV and UV tubes because both tubes had a very high 254 nm transmittance and were positioned at the same distance to the lamp surface. Nitrogen gas was flushed through the inner chamber of the photo-reactor, to eliminate the air absorption (primarily O_2) of VUV and thus maximize the VUV light reaching the reaction solution. By using the chemical actinometers of uridine and methanol, the VUV and UV FRs (*i.e.*, $E_{\text{o,VUV}}$ and $E_{\text{o,UV}}$) were determined to be 1.7 and 14.5 mW cm^{-2} , respectively. An UV-Vis spectrophotometer (2600, Shimadzu, Japan) was installed in the MVPS to provide online absorbance measurements.

Experimental procedures and reduction equivalent exposure time

After a 15 min lamp equilibration period, the phenol solution of 50 mL was circulated in the MVPS by a peristaltic pump. Samples of 1 mL each were taken out at preselected times for chemical analysis. During the MVPS runs, the reaction solution was recirculated sequentially through the exposure section (*i.e.*, the VUV/UV or UV tube) and the dark section until a desired fluence was reached. The reduction equivalent exposure time (t_{ree} , s) is defined as the total reaction time (t , s) multiplied by the ratio of the exposure volume of the operation tube ($\pi r^2 h$, m^3) to the total sample volume (V , m^3):

$$t_{\text{ree}} = \frac{\pi r^2 h}{V} t \quad (7)$$

where r and h are the radius and the length of the VUV/UV (or UV) tube, respectively. In other words, t_{ree} represents the exposure time when the whole reaction solution receives the exposure under the same exposure conditions (*i.e.*, the same $E_{\text{o,UV}}$ and $E_{\text{o,VUV}}$) in the relevant tube. The VUV (F_{VUV} , mJ cm^{-2}) or UV (F_{UV} , mJ cm^{-2}) fluences can be estimated as follows:



$$F_{\text{VUV}} = E_{\text{o,VUV}} t_{\text{ree}} \quad (8)$$

$$F_{\text{UV}} = E_{\text{o,UV}} t_{\text{ree}} \quad (9)$$

Results and discussion

Phenol absorption spectrum and degradation kinetics and TOC reduction in the MVPS

Fig. 1 shows the absorption spectra of H_2O_2 , FeCl_3 and phenol. Note that the mercury resonance lines at 185/254 nm (*i.e.*, in the VUV/UV tube) or 254 nm (*i.e.*, in the UV tube) irradiations were used throughout this study. The molar absorption coefficients of H_2O_2 , phenol and $\text{Fe}(\text{III})$ increased towards shorter wavelengths. The light absorption of H_2O_2 was so low that it could not absorb a significant amount of VUV/UV and UV photons at the low concentrations (*i.e.*, mostly 0.147 mM) used in the MVPS. The Fe (d-d) transitions take place in the nanosecond time scale, and the intensity of these transitions giving rise to the $\text{Fe}(\text{III})$ -spectrum depends on the counter-ion, pH and $\text{Fe}(\text{III})$ concentration.^{41,42}

Fig. 2a shows the phenol degradation by the dark Fenton, UV or VUV/UV photolysis, UV photo-Fenton, and VUV/UV photo-Fenton processes at an initial pH of 3.7. The VUV/UV in the absence of the Fenton's reagent ($\text{Fe}^{2+/3+}/\text{H}_2\text{O}_2$) induced phenol degradation due to the VUV (185 nm) light generating HO^\bullet from the photolysis of water.^{43,44} Without UV and VUV irradiation, little phenol degradation was found although both Fe^{3+} and H_2O_2 were present. UV and VUV/UV photo-Fenton processes led to a complete phenol degradation within 6–8 min. The photochemical behavior of the $\text{Fe}(\text{III})$ -aqua complexes plays a determining role in pollutant degradation.^{35,36} At pH 3.7 in this study, $\text{Fe}(\text{H}_2\text{O})_6^{3+}$ was partially transformed into $\text{Fe}(\text{III})(\text{OH})(\text{H}_2\text{O})_5^{2+}$, which was able to undergo ligand-to-metal-charge-transfer. This transformation depends on the excitation wavelength and involves inner sphere photo-induced electron transfer leading

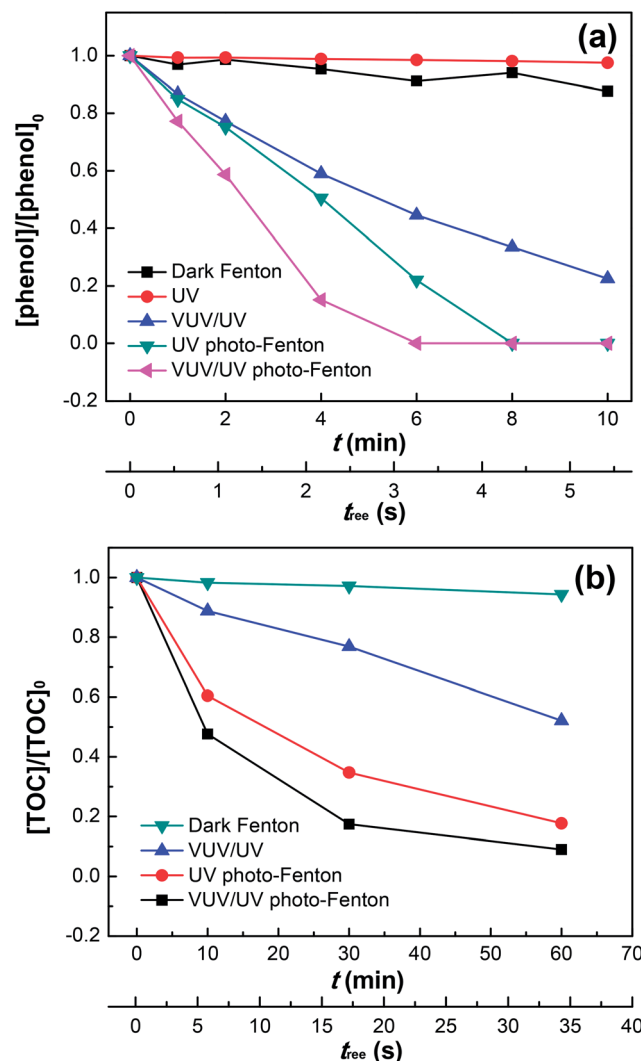


Fig. 2 Phenol degradation (a) and TOC removal (b) in the dark Fenton, UV, VUV/UV, UV photo-Fenton and VUV/UV photo-Fenton processes at $\text{pH}_0 = 3.7$. Experimental conditions: (a) $[\text{phenol}]_0 = 0.011$ mM, $[\text{H}_2\text{O}_2]_0 = 0.147$ mM, $[\text{Fe}^{3+}]_0 = 0.05$ mM; and (b) $[\text{phenol}]_0 = 0.055$ mM, $[\text{H}_2\text{O}_2]_0 = 0.735$ mM, $[\text{Fe}^{3+}]_0 = 0.25$ mM.

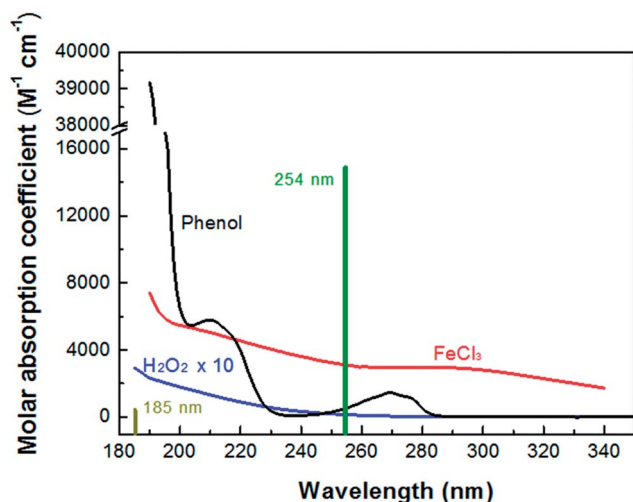


Fig. 1 Absorption spectra of H_2O_2 , FeCl_3 and phenol and mercury resonance lines at 254 and 185 nm of the low-pressure mercury lamp.

to the $\text{Fe}(\text{II})$ -aqua complex (*i.e.*, $\text{Fe}(\text{II})(\text{H}_2\text{O})_6^{2+}$) and HO^\bullet , as shown in eqn (5) above.

The HO^\bullet leading to phenol degradation was generated by the VUV (185 nm) photolysis of water and the Fe^{3+} photo-reduction. In addition, VUV also generates H^\bullet and e_{aq}^- in aqueous solutions due to homolysis and water ionization.^{43,44} Fig. 2a shows that UV (254 nm) by itself did not lead to phenol degradation. The VUV (185 nm) photons preferentially react with water (concentration of 55.6 M) compared to phenol (0.011 mM). Hence, the VUV (185 nm) photon absorption by phenol only contributed marginally to the phenol degradation (see Table 1). When H_2O_2 and Fe^{3+} were added during phenol degradation under UV or VUV/UV irradiation, the higher efficiency of phenol degradation could be explained by the effective $\text{Fe}(\text{II})/\text{Fe}(\text{III})$ inter-conversion and subsequently the higher generation of oxidative radicals. The $\text{Fe}(\text{OH})(\text{H}_2\text{O})_5^{2+}$ may also react with dissolved oxygen in the reaction solution to form $\text{O}_2^{\bullet-}$, thus



Table 1 Solution parameters determining the light absorption during phenol degradation in the MVPS^a

Reactant	<i>C</i> (mM)	ϵ_{254} (M ⁻¹ cm ⁻¹)	ϵ_{185} (M ⁻¹ cm ⁻¹)	<i>A</i> ₂₅₄	<i>A</i> ₁₈₅	<i>P</i> ₂₅₄ (%)	<i>P</i> ₁₈₅ (%)
H ₂ O	55 600	0.0002	0.03	0.01	1.8	5.7	68.1
Phenol	0.011	472	39 178	0.005	0.431	3.0	16.3
H ₂ O ₂	0.147	19	341	0.003	0.050	1.6	1.9
FeCl ₃	0.05	3140	7250	0.157	0.363	89.7	13.7
Total				0.175	2.644	100	100

^a *C* is the molar concentration of each solution component; ϵ_{254} and ϵ_{185} are the molar absorption coefficient of each solution component at 254 and 185 nm, respectively; *A*₂₅₄ and *A*₁₈₅ are the absorbance of each solution component for 1 cm optical path length at 254 and 185 nm, respectively ($A_{254} = \epsilon_{254} \times C$ and $A_{185} = \epsilon_{185} \times C$); *P*₂₅₄ is the ratio of *A*₂₅₄ of a specific solution component to the sum of *A*₂₅₄ of all solution components (*i.e.*, total *A*₂₅₄ = 0.175); and *P*₁₈₅ is the ratio of *A*₁₈₅ of a specific solution component to the sum of *A*₁₈₅ for all solution components (*i.e.*, total *A*₁₈₅ = 2.644).

enhancing the phenol degradation. It has been reported that dissolved oxygen is able to enhance Fenton/photo-Fenton reactions.^{37,38}

Fig. 2b presents the mineralization of phenol under different irradiation conditions up to 60 min. Only 90% of the initial phenol was converted into CO₂ in the VUV/UV photo-Fenton process. This suggests the existence of long-lived organic intermediates in the reaction solution, such as catechol, hydroquinone, *p*-benzoquinone and resorcinol as reported by Zazo *et al.*,²⁴ which probably accounts for the tail after 30 min. Note that a higher concentration of phenol, H₂O₂ and Fe³⁺ was used here than that in Fig. 2a, because TOC could only be measured accurately at a higher phenol concentration (*i.e.*, 0.055 mM). The total mineralization reaction of phenol can be written as follows:



The fractions of the incident photons absorbed by each solution component (*i.e.*, Fe³⁺, H₂O₂, phenol, and H₂O) during the TOC removal (Fig. 2b) is shown Fig. S2 (ESI†).

Effects of initial phenol, H₂O₂ and Fe³⁺ concentrations on phenol degradation kinetics

Fig. 3a shows phenol degradation as a function of the initial phenol concentration in the range of 0.011–0.266 mM. High concentrations of phenol decreased the degradation rate, due to the competition for the oxidative radicals in solution. In addition, the increasing phenol concentration would induce a higher fraction of UV (254 nm) photons absorbed by phenol, leaving less photons for the photo-reduction of Fe³⁺ (see eqn (5)). Similarly, this would also lower the amount of HO[•] generated by the VUV photolysis of water. Therefore, at high concentrations of phenol, the radicals generated by the Fenton's reagent (Fe^{2+/3+}/H₂O₂) would not be enough to degrade effectively an increased amount of phenol. Although secondary reactions due to these oxidative radicals still led to the degradation of phenol, only a low efficiency was observed.^{5,7,48}

Fig. 3b shows that the degradation rate of phenol increased with increasing H₂O₂ concentration, which implies that the interaction of H₂O₂ with phenol was significant. This can be explained by the photolysis of the intermediate complex/excimer [Fe³⁺...phenol...H₂O₂] in solution.^{23–27} H₂O₂ could

also scavenge HO[•] in solution,^{11–14} but this was not significant at H₂O₂ concentrations used in this study (*i.e.*, ≤2.941 mM). Hence, no inhibition of phenol degradation was seen in Fig. 3b.

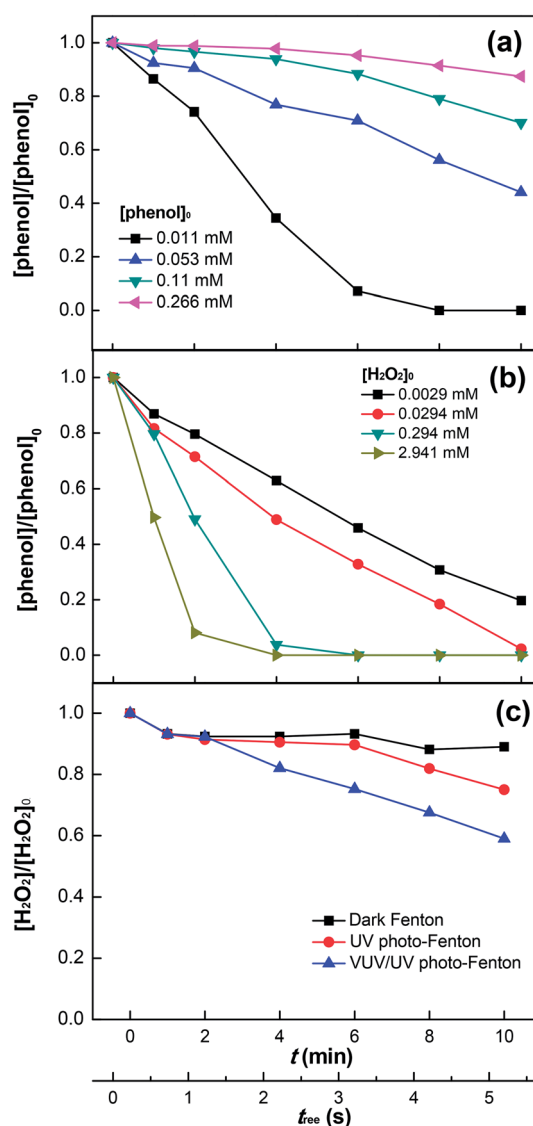


Fig. 3 Effects of initial concentrations of phenol (a) and H₂O₂ (b) on phenol degradation as well as H₂O₂ decomposition (c) in the VUV/UV photo-Fenton process. Experimental conditions: [phenol]₀ = 0.011 mM, [H₂O₂]₀ = 0.147 mM, [Fe³⁺]₀ = 0.05 mM, and pH₀ = 3.7.

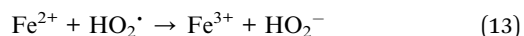
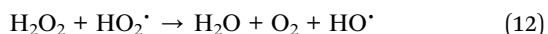
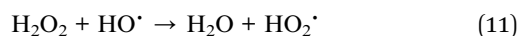


Moreover, the increasing Fe^{3+} concentration (up to 0.5 mM) could also enhance the phenol degradation (see Fig. S3, ESI†), which allowed Fe^{3+} to absorb more 254 and 185 nm photons (see eqn (5)), thus enhancing the HO^\bullet generation. Concomitantly, this would also decrease the fraction of photons absorbed by H_2O_2 and subsequently the HO^\bullet generation through H_2O_2 photolysis (see eqn (6)). Comparatively, the negative effect of the decreased H_2O_2 photolysis was less significant. The Cl^- ions added with FeCl_3 could substitute water in the first coordination sphere of $\text{Fe}(\text{OH})(\text{H}_2\text{O})_5^{2+}$ to yield mixed ligand complexes, such as $\text{FeCl}(\text{H}_2\text{O})_5^{2+}$ and $\text{FeCl}_2(\text{H}_2\text{O})_4^+$.^{41,45,46}

Fig. 3c shows the H_2O_2 consumption during phenol degradation. It is readily seen that using the Fenton's reagent in the dark led to a small H_2O_2 consumption due to the slow radical generation (*i.e.*, HO^\bullet and HO_2^\bullet) (see eqn (1) and (3)). A higher H_2O_2 consumption was observed when UV irradiation was applied. The reason is that more H_2O_2 was consumed by Fe^{2+} , which was effectively photo-generated from Fe^{3+} (see eqn (4) and (5)), and by HO^\bullet in the radical scavenging process as well. Under VUV/UV irradiation, a significant increase in H_2O_2 consumption was observed compared to that under UV irradiation, because of the enhanced Fe^{3+} reduction, water photolysis,^{43,44} and H_2O_2 photolysis by the VUV light.

The VUV light generates radicals and ions in water as reported by previous researchers.^{43,44} VUV photolysis of water leads to both radicals HO^\bullet , HO_2^\bullet , $\text{O}_2^{\bullet-}$, H^\bullet and stable species such as H_2O_2 and O_2 . In this study, the kinetics of phenol degradation depended on the absorbers in the UV and VUV regions (see Table 1). Even though the H_2O_2 /UV process presents similarities with the VUV/UV process, there are substantial differences: (a) in the H_2O_2 /UV process, the photolysis of H_2O_2 only generates HO^\bullet ; whereas in the VUV/UV process, the photolysis of water generates HO^\bullet , H^\bullet and e_{aq}^- ($\text{H}_2\text{O} + h\nu$ (185 nm) $\rightarrow \text{HO}^\bullet + \text{H}^\bullet + \text{e}_{\text{aq}}^-$), which modifies the observed radical reactions.^{43,44} The direct addition of e_{aq}^- to H_2O_2 during VUV irradiation (*i.e.*, $\text{H}_2\text{O}_2 \rightarrow \text{HO}_2^{\bullet-} + \text{H}^\bullet$) was not possible in the Marcus inverse region,⁸ because the activation energy necessary for this reaction was not available.

The decomposition of H_2O_2 produced the oxidative radicals HO^\bullet (in the first place) and HO_2^\bullet (to a lesser degree), as demonstrated by the scavenging experiments with TBA and BQ (see Fig. 4). The decomposition of H_2O_2 involves eqn (1), (2) and (6) as well as additionally the reactions reported in literature:^{31,37,47}



Eqn (11) and (15) denote the scavenging and recombination of HO^\bullet , respectively. As the H_2O_2 concentration increased, both reactions fostered the decomposition of H_2O_2 .

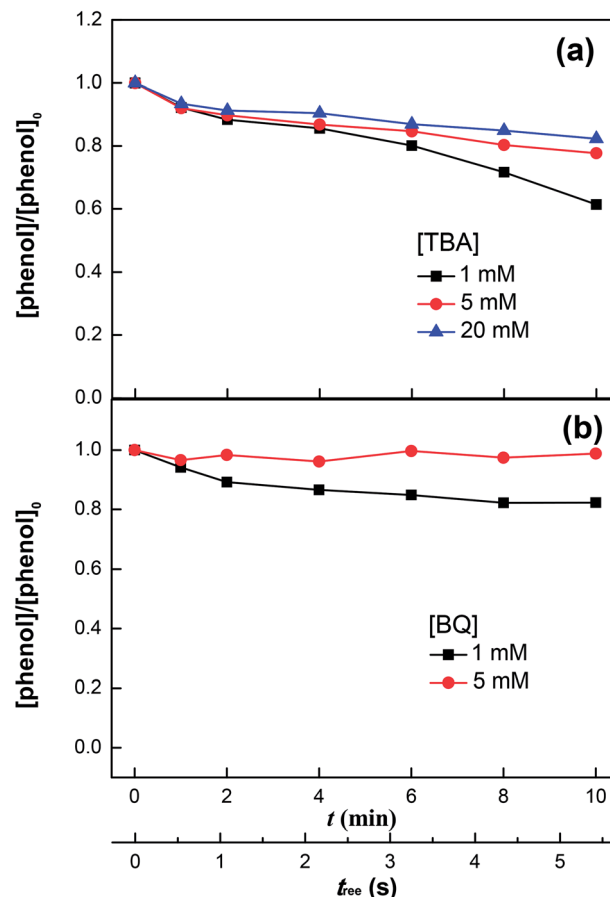
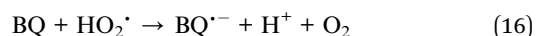


Fig. 4 Phenol degradation in the VUV/UV photo-Fenton process in the presence of *tert*-butanol (TBA) (a) and benzoquinone (BQ) (b). Experimental conditions: $[\text{phenol}]_0 = 0.011$ mM, $[\text{H}_2\text{O}_2]_0 = 0.147$ mM, $[\text{Fe}^{3+}]_0 = 0.05$ mM, and $\text{pH}_0 = 3.7$.

Identification of oxidative radicals produced in the VUV/UV photo-Fenton process

Fig. 4a shows the phenol degradation under VUV/UV irradiation with TBA used as a HO^\bullet scavenger. HO^\bullet is scavenged by TBA with a reaction rate of $1.9 \times 10^9 \text{ M}^{-1} \text{ s}^{-1}$ and reacts with phenol at a diffusion controlled reaction rate of $9.6 \times 10^9 \text{ M}^{-1} \text{ s}^{-1}$.⁴⁷ It is readily seen that increasing the TBA concentration inhibited phenol degradation due to the quenching of the HO^\bullet .

Fig. 4b shows the phenol degradation in the presence of BQ, an HO_2^\bullet scavenger. The phenol degradation slowed down at higher BQ concentrations. BQ scavenges HO_2^\bullet with a reaction rate of $9.6 \times 10^8 \text{ M}^{-1} \text{ s}^{-1}$ according to the reaction:



Mechanism for phenol degradation by Fenton's reagent under VUV/UV irradiation

Fig. 5a shows the effect of initial pH on phenol degradation in the VUV/UV photo-Fenton process. Both $\text{Fe}(\text{OH})^{2+}$ reduction and H_2O_2 hydrolysis under UVC light (see eqn (5) and (6)),



generated additional HO^\bullet compared to the dark Fenton system.^{31,34,46} The Fe(III) -aqua complexes present different molar absorption coefficients and optical absorption wavelength ranges as a function of the solution pH.^{35,36} This in turn induced a different rate of phenol degradation and quantum yield as a function of pH. The highest phenol degradation rate was found at pH 3.7. At this pH, the initial fully coordinated Fe^{3+} ion under strongly acidic conditions, $\text{Fe}(\text{H}_2\text{O})_6^{3+}$, could incorporate an OH^- group in its structure leading to the formation of $\text{Fe}(\text{OH})(\text{H}_2\text{O})_5^{2+}$.^{35,36,42} Under UVC light irradiation, $\text{Fe}(\text{OH})(\text{H}_2\text{O})_5^{2+}$ led to the formation of HO^\bullet (see eqn (5)). The relatively

slower phenol degradation rates at pHs 2.1 and 3.1 were probably due to the acidic Fe -aqua complexes substituted by Cl^- in the first coordination sphere such as $\text{FeCl}(\text{H}_2\text{O})_5^{2+}$ and $\text{FeCl}_2(\text{H}_2\text{O})_4^{2+}$.⁴⁷ At pH 5.2, the Fe -aqua complex, $\text{Fe}(\text{OH})_2(\text{H}_2\text{O})_4^+$, incorporated progressively one more OH^- group slowing down the phenol degradation rate.⁴⁸ The degradation of other organic pollutants by photo-Fenton processes have been reported recently.^{49,50}

Fig. 5b shows that during phenol degradation under VUV/UV irradiation, the solution pH moved slightly to more basic values. This suggests that the phenol degradation was mainly due to the $\text{HO}^\bullet/\text{OH}^-$ conversion. Fenton reactions induced the hydroxylation of the aromatic ring of phenol through the hydroxy-cyclohexadienyl radical by the addition of HO^\bullet , which subsequently led to the formation of quinones and other intermediates shown in Fig. 5c and also found during phenol degradation by the Fenton's reagent by Zazo *et al.*²⁴ A mechanistic cycle for phenol degradation in the dark and by a photo-Fenton system under UVC irradiation is suggested in Fig. 5c.

Light absorption by each solution component during phenol degradation with various initial concentrations

Although the effect of initial phenol concentration on its degradation kinetics was already examined in Fig. 3a, the specific contribution of the highly oxidative radical species leading to phenol degradation has not been completely elucidated. This remains a controversial issue. Fig. 6a shows the fraction variation of the 185 nm photons absorbed by each solution component as a function of the phenol concentration. For the degradation of low-concentration phenol (*i.e.*, $[\text{phenol}]_0 = 0.011 \text{ mM}$) by the VUV/UV photo-Fenton process, the fraction of 185 nm photons absorbed by water was 68.1%, while those by phenol and FeCl_3 were 16.3% and 13.7%, respectively, indicating that the effect of the additional VUV irradiation was the HO^\bullet generation from VUV photolysis of water as compared to that of the UV photo-Fenton process. The enhancement for Fe^{3+} reduction and direct photolysis of phenol by the VUV (185 nm) light was rather small. When the phenol concentration increased to 0.266 mM, phenol could absorb 82.5% of the 185 nm photons. In this case, the HO^\bullet generation through VUV photolysis of water became much less important.

Fig. 6b shows the fraction of the 254 nm photons absorbed by each component in the solution as a function of phenol concentration. Because of the low molar absorption coefficient of water at 254 nm (see Table 1), the photon absorption by water was not significant. For a low phenol concentration, Fe^{3+} could absorb most of the 254 nm photons. However, when the phenol concentration increased from 0.011 to 0.266 mM, the fraction of the 254 nm photons absorbed by phenol increased from 3.0% to 42.5%, which considerably decreased the generation of HO^\bullet through eqn (4)–(6).

The results of photon absorption by the components in solution show that under UV and VUV irradiations, the 254 and 185 nm photons absorbed by phenol itself played an important role in phenol degradation, especially when the phenol concentration was high. The ionization of phenol requires

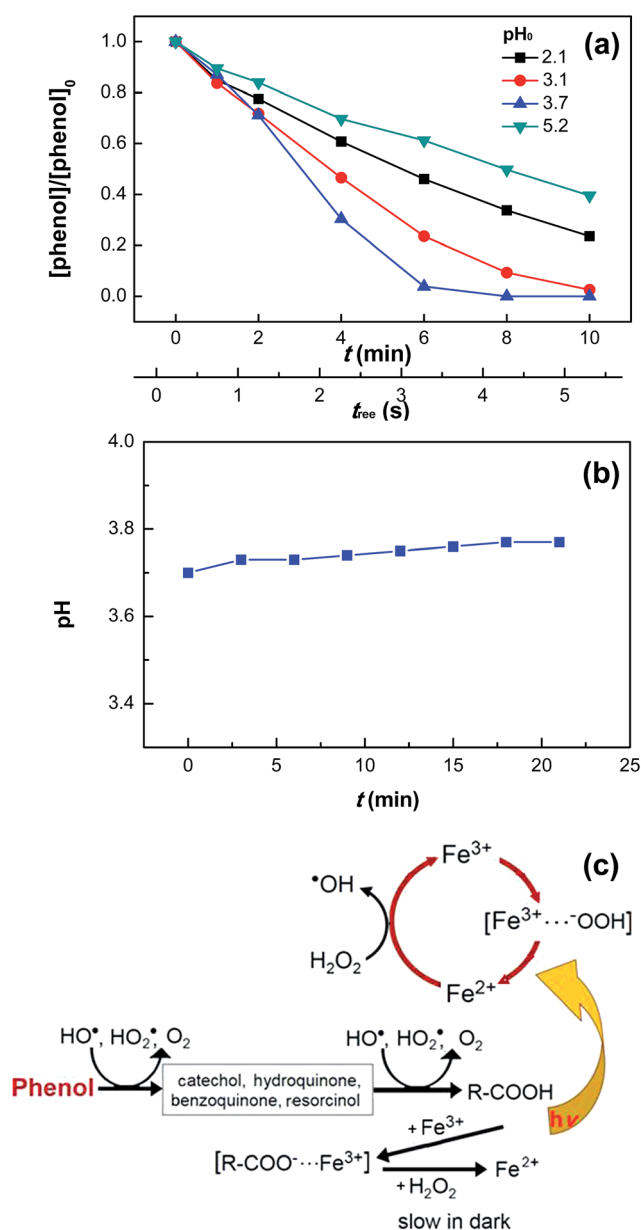


Fig. 5 Phenol degradation at various initial pH values (a) and pH variation ($\text{pH}_0 = 3.7$) (b) in the VUV/UV photo-Fenton process as well as proposed reaction mechanisms for the dark Fenton and VUV/UV photo-Fenton processes (c). Experimental conditions: $[\text{phenol}]_0 = 0.011 \text{ mM}$, $[\text{H}_2\text{O}_2]_0 = 0.147 \text{ mM}$, and $[\text{Fe}^{3+}]_0 = 0.05 \text{ mM}$.

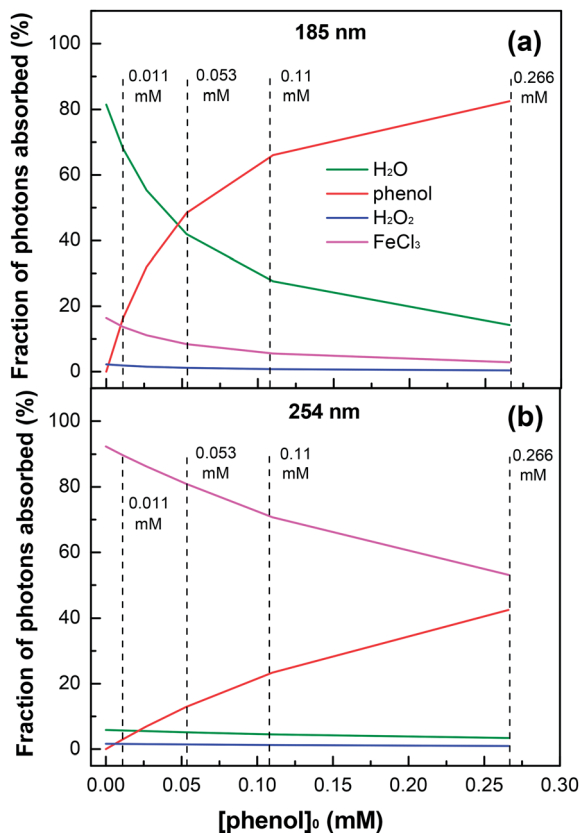
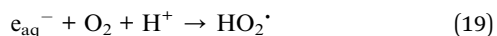
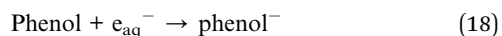
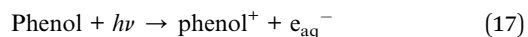


Fig. 6 Fractions of 185 (a) and 254 nm (b) photons absorbed by each solution component as a function of initial phenol concentration in the VUV/UV photo-Fenton process. Experimental conditions: $[\text{H}_2\text{O}_2]_0 = 0.735 \text{ mM}$, $[\text{Fe}^{3+}]_0 = 0.25 \text{ mM}$, and $\text{pH}_0 = 3.7$.

8.50 eV and may go through either a mono-photonic or bi-photonic absorption process. The 185 nm light is made up of 6.70 eV photons; therefore, it might induce a mono-photonic ionization of phenol. For the 254 nm photons (4.87 eV), a bi-photonic ionization of phenol was likely to occur. The ionization reactions are presented in eqn (17)–(19). These results demonstrate that the phenol concentration strongly affected its degradation kinetics and the VUV/UV photo-Fenton process was most suitable for the treatment of dilute phenol solutions.



Conclusions

This study addressed the optimization of the solution parameters leading to the enhanced abatement of phenol in a mini-fluidic VUV/UV photoreaction system. The phenol degradation required a reduced consumption of electricity because the VUV light was made full use. By the VUV/UV mercury resonant lines

(185/254 nm), water and H₂O₂ generated the highly oxidative radicals (HO[•] and HO₂[•]) leading to phenol degradation. The generation of these oxidative radicals was further increased in the presence of Fe³⁺ ions in the photo-Fenton processes. The oxidative radicals which intervened in the phenol degradation were identified. In addition, the fraction of the incident photons absorbed by each solution component was quantified. For a dilute phenol solution (0.011 mM), the fraction absorbed by phenol was 16.3% for the VUV photons (185 nm) and 3.0% for the UV photons (254 nm), while for a high-concentration phenol solution (0.266 mM), the fraction increased to 82.5% (185 nm photons) and to 42.5% (254 nm photons). Due to a relatively low electrical energy used to generate the oxidative radicals to abate phenol, the VUV/UV photo-Fenton process has potential applications in the treatment of industrial wastewater containing phenol and related aromatic pollutants.

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